# **Application Note**

DSA20060715: Scratch Analyzer

## **FEATURES**

Pre-process KLARF data

Detect Scratches

Output



#### Introduction

DSA Release 8.2 use one scratch analyzer function: **Thin Scratch Analyzer/Filter**. This function allows users to analyze either straight or thin arc scratches (sparse or adjacent, isolated or intersecting, etc.) on wafer surface. Thin Scratch Analyzing/Filtering is comprised of three steps:

- 1. Pre-process KLARF data, which is filtering by classification attributes;
- 2. Detect Scratches.
- 3. Output.

### **Pre-process KLARF data**

The input data to the **Thin Scratch Analyzer/Filter** may be **filtered by classification attributes** (e.g., ClassNum).

- Check Filter by Classification Attributes before processing to filter data by the defect's classification type before performing the object analysis.
- Press the Settings button to view the dialog box below:

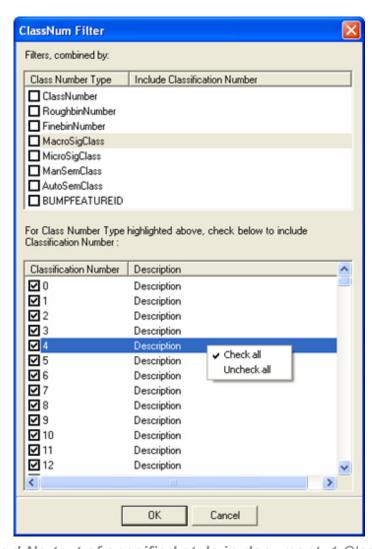


Figure Error! No text of specified style in document. 1 ClassNum filter



• Select Class Number Type by checking a field from its list.

Refer to Filter by ClassNum for the usage of the check box "Filter by Classification Attributes before processing".

#### **Detect Scratches**

This function can find and analyze three types of thin scratch:

- 1. **Straight Scratches**: Check this option to detect and view only straight thin scratches on the result file.
- 2. **Short Scratches**: Check this option to detect and view only isolated short and thin scratches of which length is less than approximately 30,000 µm and thickness is less than approximately 400 µm.
- 3. Arc Scratches: Check this option to detect and view only acr thin scratches on the result file.
  - Check *Sparse Arc Scratches* to also detect and view the thin scratches with low density on the result file.
  - Press the **Filter Conditions** button to filter and keep only the arc scratches that satisfy the parameters user sets in the dialog box below:
  - The Arc tab:

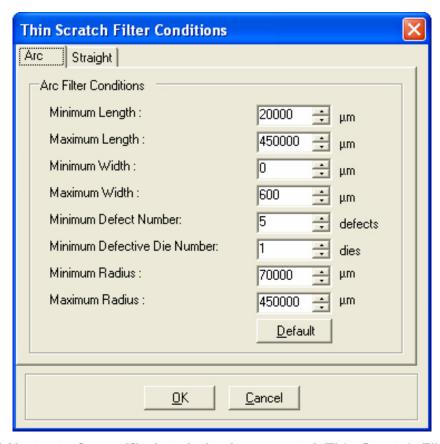


Figure Error! No text of specified style in document. 2 Thin Scratch Filter conditions - Arc



- Minimum/Maximum Length: the acceptable minimum/maximum length of the thin arc scratch to be filtered.
- Minimum/Maximum Width: the acceptable minimum/maximum width of the thin arc scratch to be filtered.
- Minimum Defect Number: the acceptable minimum number of defects in the thin arc scratch to be filtered.
- *Minimum Defective die Number*: the acceptable minimum number of defective dies in the thin arc scratch to be filtered.
- *Minimum/Maximum Radius*: the acceptable minimum/maximum radius of the thin arc scratch to be filtered.

The **Default** button allows user to reset all parameters to default values.

• The Straight tab:

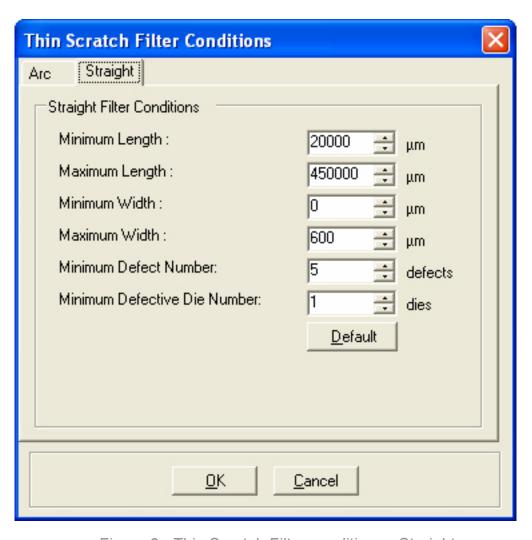


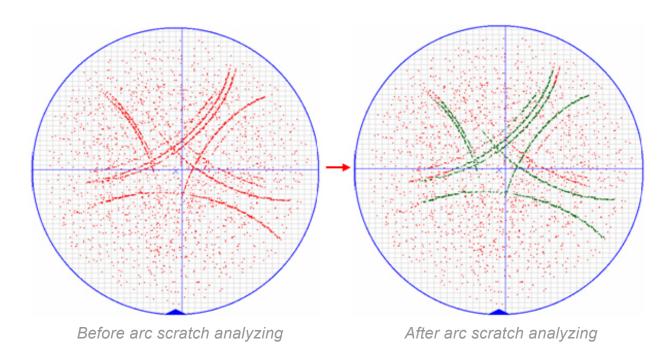
Figure 3 Thin Scratch Filter conditions - Straight



- *Minimum/Maximum Length:* the acceptable minimum/maximum length of the thin straight scratch to be filtered.
- *Minimum/Maximum Width:* the acceptable minimum/maximum width of the thin straight scratch to be filtered.
- *Minimum Defect Number:* the acceptable minimum number of defects in the thin straight scratch to be filtered.
- *Minimum Defective die Number:* the acceptable minimum number of defective dies in the thin straight scratch to be filtered.
- Press **OK** to accept the settings.

#### **Example:**

The figure below illustrates a KLARF file before and after being processed with Thin Scratch Analyzer.



The green scratches shown above are thin arcs.

- To view and keep only these scratches on wafer, click the **Show Analyzed Data** button from the wafer toolbar.
- To select an arc, left click on any point belonging to the arc, the whole arc will be highlighted in light green.
- To view an arc's information as shown below, select and right click on it.



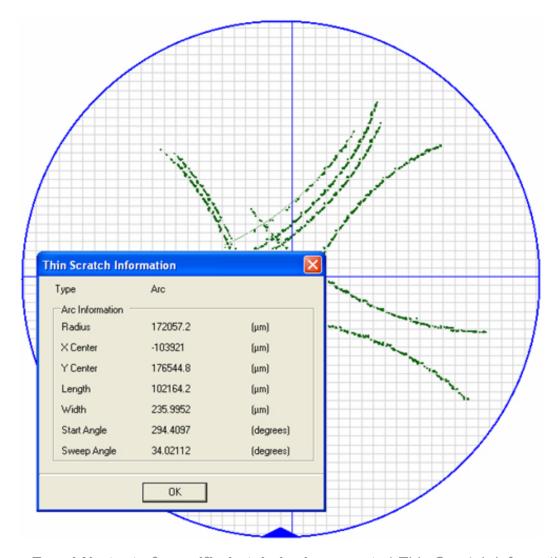


Figure Error! No text of specified style in document. 4 Thin Scratch information

## **Output**

The output options are only applied to Thin Scratch Filter function.

- Select one of the Output Options:
  - Keep Scratch defects only: Analyze defects and keep in the current results file only the scratches that meet the criteria set above.
  - Clear Scratch defects from defect list: Analyze defects and filter out from the defect list all the scratches that meet the criteria set above.
  - Classify Scratches: Assign classification attributes (e.g. ClassNum Type) to all scratches that meet the criteria above. Press the Arc Scratch Classification button to specify three types of classification as follows:



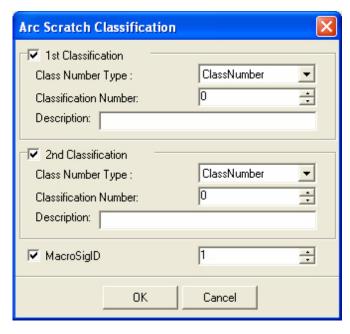


Figure Error! No text of specified style in document. 5 Arc Scratch Classification

Classify defects by checking 1st Classification, 2nd Classification and/or MacroSigID. Enter the Classification Number and Description of the scratch signature.

Press **OK** to accept the defined type of classification into output result.

- *Update Cluster ID*: After analysis, the Cluster ID of original KLARF file will change according to the analyzing results. This option is used to update new Cluster ID into the output file.
- Press **OK** to finish the task and view the result wafer map.

#### Example:

The image below illustrates a KLARF file before and after being processed with Thin Scratch Filter.

